PATENT APPLICATION Docket No. 4591-227 Client No. IE10176-US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Do-Hyung KIM and Sung-Eui KIM

Scrial No.

10/083,756

Examiner:

Vu. Quang D

Confirmation No.

2262

Filed:

February 25, 2002

Group Art Unit: 2811

For:

METHOD FOR FORMING LAYER FOR TRENCH ISOLATION

STRUCTURE

MAIL STOP AMENDMENT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

AMENDMENT

Responsive to the Office Action, dated August 24, 2004, please amend the application as follows.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.